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Extraordinary Second Harmonic Generation in Tungsten Disulfide Monolayers

SUBJECT AREAS:

SURFACES, INTERFACES
AND THIN FILMS

NONLINEAR OPTICS

TWO-DIMENSIONAL MATERIALS

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We investigate Second Harmonic Generation (SHG) in monolayer WS₂ both deposited on a SiO₂/Si substrate or suspended using transmission electron microscopy grids. We find unusually large second order nonlinear susceptibility, with an estimated value of $d_{\text{eff}} \sim 4.5$ nm/V nearly three orders of magnitude larger than other common nonlinear crystals. In order to quantitatively characterize the nonlinear susceptibility of two-dimensional (2D) materials, we have developed a formalism to model SHG based on the Green's function with a 2D nonlinear sheet source. In addition, polarized SHG is demonstrated as a useful method to probe the structural symmetry and crystal orientation of 2D materials. To understand the large second order nonlinear susceptibility of monolayer WS₂, density functional theory based calculation is performed. Our analysis suggests the origin of the large nonlinear susceptibility in resonance enhancement and a large joint density of states, and yields an estimate of the nonlinear susceptibility value $d_{\text{eff}} = 0.77$ nm/V for monolayer WS₂, which shows good order-of-magnitude agreement with the experimental result.

Two-dimensional (2D) materials, exhibiting extraordinary and novel properties not available in their bulk forms, are at the forefront of nanomaterial technologies^{1–8}. For instance, the transition metal dichalcogenide (TMD) family of monolayer materials (such as MoS₂, WS₂), unlike their bulk counterparts, possesses direct band gaps^{9–12} and could thus generate strong photoluminescence^{13–17}. The TMD family of monolayer materials have also garnered interest in nonlinear optics^{18,19}. Characterization of exfoliated WS₂²⁰ and synthesized MoS₂ monolayers^{21–23} has revealed large second-order nonlinear susceptibility, as high as nm/V^{22,23}. Here we investigate SHG in monolayer WS₂ synthesized by chemical vapour deposition. We have developed a formalism to model SHG in 2D materials using the Green's function with a 2D nonlinear sheet source, which also takes into account the focused excitation geometry and the substrate effect as opposed to a simple plane-wave model. SHG in WS₂ monolayers both suspended and deposited on SiO₂/Si substrates is studied. The estimated second order nonlinear susceptibility is approximately three orders of magnitude higher than that of common nonlinear optical crystals such as BBO²⁴. Polarized SHG in WS₂ is studied to probe the tensorial nonlinear susceptibility, which is related to the structural symmetry of the 2D crystal. To gain further insight into the large nonlinear susceptibility, density functional theory (DFT) calculations of the second-order nonlinear susceptibility are also performed.

Results

A WS₂ monolayer lacks inversion symmetry and has non-vanishing second-order nonlinear susceptibility. An experimental setup was developed to characterize the SHG in the synthesized WS₂ samples (Fig. 1a). Fig. 1(b) shows an optical micrograph of a triangular monolayer of WS₂ grown on a SiO₂/Si substrate. The same triangle is also shown as an SHG image in Fig. 1(c), obtained by raster scanning the sample with a step size of 1 μm. As can be observed from the SHG image, the background contribution from the substrate surface in the surrounding area is negligible. To further isolate substrate effects, the same experiments were also performed on a WS₂ sample that was suspended on a transmission electron microscopy (TEM) grid. Fig. 1(d) shows an optical micrograph of the WS₂ film on the TEM grid, and Fig. 1(e) shows the SHG image of the same triangle. Although the WS₂ triangle can

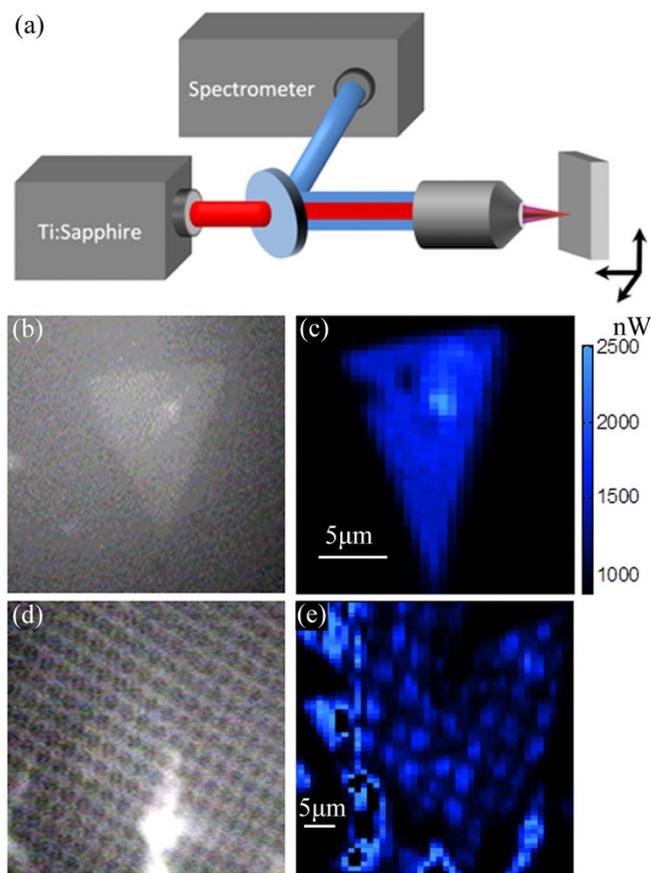


Figure 1 | (a) Schematic diagram of the experimental setup for characterizing SHG in WS₂ monolayers. The fundamental beam is from a mode-locked Ti:sapphire laser (832 nm center wavelength, 88 MHz repetition rate) and the second harmonic signal generated by the WS₂ monolayer is epi-collected and measured using a spectrometer. (b) Optical micrograph of a synthesized triangular WS₂ monolayer grown on a SiO₂/Si substrate. (c) SHG image of the same WS₂ triangle obtained by raster scanning the sample. (d) Optical micrograph of a synthesized triangular WS₂ monolayer placed on a transmission electron microscopy grid. (e) SHG image of the same WS₂ triangle obtained by raster scanning the sample.

barely be seen on the TEM grid micrograph due to weak reflection contrast, the triangle is easily apparent in the SHG image. A depth scan was also performed on the WS₂ samples and bare substrates to measure the SHG signal as a function of sample depth position, by translating the sample axially with a computer-controlled linear stage. The results shown in Fig. 2(a) indicate that the Second Harmonic (SH) signals generated from both the on-substrate and suspended samples are predominantly from the WS₂ monolayers, as the bare substrates had no detectable SH signal under the same measurement conditions. To characterize the second-order nonlinear susceptibility, we measured the average power of the SHG signal as the power of the fundamental beam was varied. Fig. 2(b) shows that the resulting relation is quadratic: a linear fit of the log-log plot reveals a slope of 2.04 for the TEM-suspended WS₂ sample, and 2.12 for the WS₂/SiO₂/Si substrate sample. The lower inset of Fig. 2(b) shows representative spectra of the fundamental and SHG signal, which also clearly indicate the frequency doubling.

Discussion

In order to quantitatively characterize the second-order nonlinear susceptibility, we have developed a formalism to model SHG from 2D materials on a semi-infinite substrate. A plane-wave fundamental

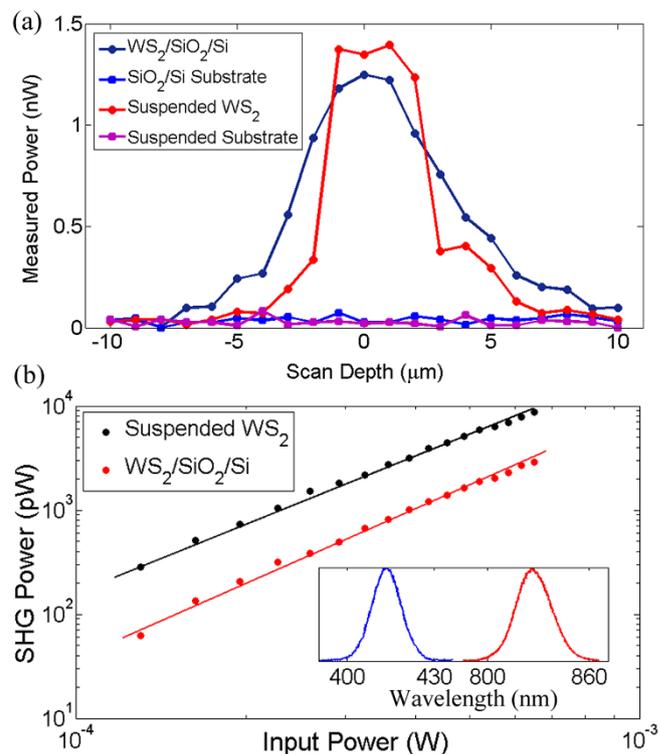


Figure 2 | (a) SHG scan with sample translated along the axial direction. The distance is relative to the surface of the substrate. The vertical axis shows the SH signals generated from WS₂ on a SiO₂/Si substrate (average incident power = 1 mW) and suspended on a TEM grid (average incident power = 0.7 mW), as well as SH signals for the bare SiO₂/Si substrate and TEM grid, by focusing the fundamental beam to different depths. There is no detectable SHG signal from the bare substrate without the WS₂ triangular monolayer, thus allowing all the SH signal generated at the surface of the sample to be attributed to the presence of WS₂. (b) Power dependence of the SH signal generated from a triangular WS₂ monolayer in a logarithmic scale on both the suspended and the SiO₂/Si substrate. The measured power is shown as points and the linear fit is plotted as a solid line. The bottom inset shows the normalized fundamental laser spectrum and a typical normalized spectrum of the SH signal generated from a WS₂ monolayer.

beam uniformly filling the aperture of a lens (focal length F , aperture radius a , numerical aperture $NA = a/F$) is focused onto the 2D material, and the generated SH signal is epi-collected. The fundamental field at the sample can be represented by the Debye integral²⁵ $E_1(x, y, 0) = \left(\frac{2}{n_1 + 1}\right) \lambda_1 E_{10} F \iint \text{circ}\left(\frac{\lambda_1 u}{NA}, \frac{\lambda_1 v}{NA}\right) e^{i2\pi(ux + vy)} dudv$, where E_{10} represents the incident field at the lens aperture, n_1 is the refractive index of the substrate at the fundamental wavelength λ_1 , and $\text{circ}()$ is the circular aperture function. The paraxial approximation is used, and the Fresnel coefficient for normal incidence is also taken into account. The SHG is governed by the wave equation $(\nabla^2 + \omega_2^2 c^{-2} n^2(z)) E_2 = -\mu_0 \omega_2^2 \epsilon_0 \hat{e}_2 \cdot \chi^{(2)} : \hat{e}_1 \hat{e}_1 E_1^2(x, y, 0)$, where E_2 is the complex SH field, \hat{e}_1 and \hat{e}_2 represent the polarization of the fundamental and SH beam, ω_2 is SH angular frequency, c is the speed of light in vacuum, ϵ_0 and μ_0 are the vacuum permittivity and permeability, and $\chi^{(2)}$ is the second-order nonlinear susceptibility tensor¹⁹. Due to its atomic thickness, the nonlinear susceptibility of the 2D material can be modelled by a Dirac delta function with an effective surface nonlinear susceptibility, i.e. $\hat{e}_2 \cdot \chi^{(2)} : \hat{e}_1 \hat{e}_1 = \chi_s^{(2)} \delta(z)$. Additionally, $n(z) = 1$ ($z < 0$) or n_2 ($z > 0$), the refractive index of the substrate at the SH frequency. The SHG from the substrate surface is



neglected, as justified by the experimental observation of no signal for the substrate background measurements of Fig. 1(c) and Fig. 2(a).

The relationship between the fundamental excitation power P_1 and the SH signal power P_2 is obtained by solving for the Green's function with the nonlinear sheet source:

$$P_2 = \frac{32NA^2(\chi_s^{(2)})^2 P_1^2}{\epsilon_0 c \lambda_2^4 (n_2 + 1)^2 (n_1 + 1)^4} \phi \quad (1)$$

with $\phi = 8\pi \int_0^1 |\cos^{-1} \rho - \rho \sqrt{1 - \rho^2}|^2 \rho d\rho$.

From Eq. (1) we can express the surface nonlinear susceptibility in terms of the average power, the pulse width, and the pulse repetition rate:

$$\chi_s^{(2)} = \sqrt{\frac{\epsilon_0 c \lambda_2^4 P_{av2} R t_1^2 (n_2 + 1)^2 (n_1 + 1)^4}{32NA^2 t_2 P_{av1}^2 \phi}} \quad (2)$$

where R is the repetition rate, t_i is the pulse width, and P_{avi} is the average power ($i = 1$: fundamental, 2 : SH). Since the WS₂ monolayer has atomic thickness much shorter than the pulse length involved, the continuous wave approximation is still valid even though chirped femtosecond pulses are used in our experiment. In our calculation, the instantaneous power of the fundamental beam is approximated by the pulse energy divided by the pulse duration time. The calculated nonlinear susceptibility represents an averaged value over the pulse bandwidth. Based on data taken similar to that of Fig. 2(b) (from 30 triangles on 3 separate substrates) and Eq. (2), the effective bulk-like second-order susceptibility of the grown WS₂ monolayers, with $d_{\text{eff}} = \chi_s^{(2)}/2T$ where $T = 0.65$ nm is the thickness of a WS₂ monolayer, was estimated to be 4.46 nm/V for the suspended film with a standard deviation of 0.09 nm/V across all samples, and 4.51 nm/V for the WS₂ triangle on a SiO₂/Si substrate with a standard deviation of 0.55 nm/V. Note that the standard deviations should be interpreted as the consistency of the measured SHG power rather than the accuracy of the susceptibility value due to the assumptions that were made in our calculation. These estimated values are nearly three orders of magnitude greater than that of typical nonlinear crystals²⁴. It should also be noted that the SiO₂/Si substrate may not be simply treated as a semi-infinite homogeneous medium due to the presence of the SiO₂/Si interface, as it is well known such substrate has contrast enhancement²⁶. The calculated nonlinear susceptibility thus needs to be adjusted by an enhancement factor, i.e., $\chi_{s\text{MAT}}^{(2)} = \eta_1^2 \eta_2 \chi_s^{(2)}$ where η_1 and η_2 are the field enhancement factors for the fundamental and the epi-detected SH field, respectively, due to the Fabry-Perot cavity formed by air/SiO₂ and SiO₂/Si interfaces.

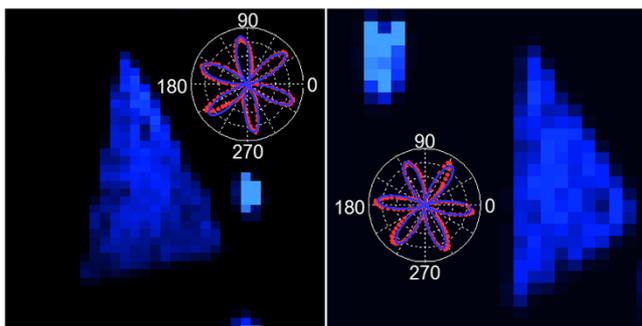


Figure 3 | Polarized SHG in WS₂ triangles. The SHG images show two monolayer WS₂ triangles on the same SiO₂/Si substrate. The polar plots show the normalized polarization dependence of SHG in WS₂ monolayer islands. Dots are measured data and the solid curves are the theoretical fit. The two polar plots reveal a rotation of 18 degrees between the two triangles.

$\chi_s^{(2)}$ is the calculated value using Eq. (2), and $\chi_{s\text{MAT}}^{(2)}$ is the actual nonlinear susceptibility. For a substrate with 300 nm of SiO₂ above silicon, the susceptibility value is estimated to be 15% more when the cavity enhancement factors are accounted. This analysis of the enhancement factor assumes a normally incident plane wave. A more rigorous approach would require angular spectrum decomposition of the incident wave. For this reason, the suspended sample is likely to yield a better estimate of the nonlinear susceptibility.

In addition to the value of d_{eff} , the tensorial property of the second-order nonlinear susceptibility of WS₂ monolayers can also be probed by polarized SHG. The WS₂ monolayer has P6₃/mmc crystal symmetry, resulting in a second-order nonlinear susceptibility tensor with nonzero elements $d_{yyy} = -d_{yxx} = -d_{xxy} = -d_{xyx}$ where x and y represent the crystal axes¹⁹. The polarized SH signal power $P_2 \propto \cos^2 3\theta$ where θ is the angle between the x crystal axis and the incidence polarization²⁷. This relationship is shown compared to experimental results in Fig. (3). Two WS₂ monolayer triangles on the same SiO₂/Si substrate are shown by SHG raster scan. The two inserts are polar plots where the circles are measured data points and the solid line is the $\cos^2 3\theta$ fit. The two polar plots are rotated by 18 degrees with respect to each other, and the left edge of the two triangle SHG images appear to be rotated by a similar angle. The experimental data and theoretical curve agree well and clearly demonstrate six-fold symmetry. As the tensor structure of $\chi^{(2)}$ is closely related to the symmetry of the material structure, polarized SHG can be a useful tool for probing the structural symmetry of 2D materials.

To understand the origin of the giant experimentally observed second-order nonlinearity we have also calculated the second-order nonlinear optical susceptibility of monolayer WS₂ at the level of density functional theory (DFT), extending beyond existing literature results in the tight binding approximation²⁸. Note that the band gap measured by photoluminescence agrees with the DFT calculation surprisingly well, due to the partial cancellation of quasi-particle effects and exciton binding²⁹. On the other hand, calculations at the quasi-particle or Bethe-Salpeter equation level are computationally expensive, due to the very fine k-point mesh required. For an accurate description of the second-order response we follow the formalism of Sipe and Ghahramani^{30–33} as implemented in the ABINIT package^{34,35}, including both inter-band transitions and intra-band currents. Although completely filled bands produce no intra-band current at the linear order, intra-band motion does occur at second order^{30,32}. The ground-state properties and response functions were calculated within the local density approximation³⁵ using norm-conserving pseudopotentials with an energy cut-off of 760 eV and

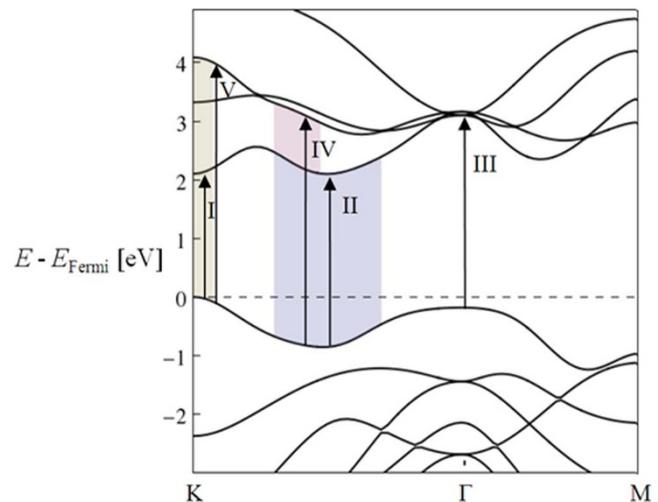


Figure 4 | The band structure of monolayer WS₂. The parallel bands along Γ -K give rise to maxima in the joint density of states.

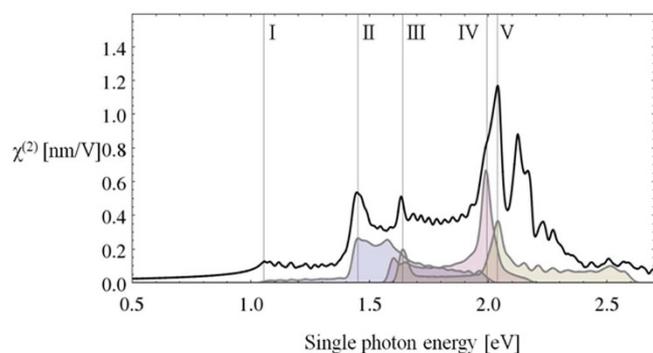


Figure 5 | The nonlinear susceptibility $\chi^{(2)}$ of monolayer WS₂. Also shown is the colour-coded joint density states contributions from the highest valence band to the first, second, and third conduction bands, aligned to the calculated spectra at the appropriate second-order resonant frequencies and following the colour scheme of Fig. 4.

a k -point mesh of $69 \times 69 \times 1$ within ABINIT^{36–40}. The optical spectra achieved convergence with 50 conduction bands and a smearing of 15 meV.

The band structure of monolayer WS₂ features three nearly parallel bands along Γ -K, as shown by the shaded areas near II and IV in Fig. 4. The highest valence band is parallel to both the first and the second conduction bands, yielding two peaks labelled II and IV in j_{ω} the joint density of states (JDOS) of Fig. 5. Another prominent feature in the JDOS, labelled V, originates from transitions near the K point. The second-order interband transition V could be strongly enhanced by the intermediate transition I at the half-way point in energy, if these matrix elements are non-vanishing. This is confirmed by the calculated nonlinear spectra.

In addition to the calculated $\chi^{(2)}$, Fig. 5 also shows the JDOS, horizontally rescaled to $j(2\omega)$ to match resonances arising from the 2ω terms and separated out by colour-coded destination bands following the same colour scheme as in Fig. 4. The main features in the JDOS match well with the calculated $\chi^{(2)}$ spectra. Resonance I has the lowest excitation energy, corresponding to half the band gap. Resonances II and IV clearly benefit from a large JDOS. Resonance V arises from transitions near the K point, which lies at almost twice the band gap (also at K). Near transition II (corresponding to a wavelength of 832 nm) we obtain $\chi^{(2)} = 0.5$ nm/V. With the simulation cell height of 2 nm, we obtain a value of $d_{\text{eff}} = 0.77$ nm/V. The calculation confirms the very large non-linear response observed experimentally, and considering the overall magnitude of the effect and the neglect of quasiparticle and excitonic effects, the semi-quantitative agreement to experiment is surprisingly good.

In summary, we report strong SHG from synthesized WS₂ monolayer islands both on SiO₂/Si substrate and suspended on a TEM grid, as well as a theoretical calculation of the second-order susceptibility using DFT. In order to experimentally determine the second-order susceptibility of 2D materials, we have developed a SHG model based on the Green's function, yielding an estimated bulk-like second-order nonlinear susceptibility d_{eff} approximately 4.5 nm/V for a WS₂ monolayer. In addition, by using polarized SHG, the crystal symmetry and orientation of the WS₂ monolayer can be revealed, demonstrating SHG as a useful method to probe structural information in 2D materials. Further analysis through DFT calculations indicate that the large second-order susceptibility is due to resonance enhancement as well as the large joint density of states. Despite the approximations involved, the calculated nonlinear susceptibility ($d_{\text{eff}} = 0.77$ nm/V) using DFT shows reasonable order-of-magnitude agreement with the experimental result. With giant $\chi^{(2)}$ and sub-nanometre thickness, the integration of 2D TMD materials with photonic circuits to realize new nonlinear optical devices could be a fertile ground worth further exploration.

Methods

Synthesis. The WS₂ triangle monolayer samples were grown on SiO₂/Si substrates using a two-step process¹⁷. Briefly, one-nm films of WO₃ (99.998%, Alfa Aesar) were thermally evaporated onto a SiO₂/Si substrate at 10^{-6} Torr. The films were placed into a quartz reaction tube next to a boat containing sulphur powder (99.5%, Alfa Aesar). The sulphur zone was heated up to 250 °C and the furnace where the WO₃ sample was located was heated to 800 °C. The synthesis was carried out in an inert environment under an Ar flow using 100 sccm and atmospheric pressure at the outlet. To verify the structural quality and integrity of the grown WS₂ monolayers, Raman spectroscopy using a Renishaw inVia micro-Raman was carried out at 514.5 nm laser excitation. The 2LA(M) phonon mode (352 cm⁻¹) had an intensity twice as high as that of the A1g mode (418 cm⁻¹), which, according to reference 41, is a characteristic of monolayer WS₂, thus confirming that the synthesized WS₂ samples are indeed monolayers.

Characterization. The output from a mode-locked Ti:sapphire laser (from KM Labs with centre wavelength of 832 nm and repetition rate of 88 MHz) was filtered, attenuated, and focused onto a sample by a long-working-distance objective lens (Mitutoyo 50 \times , NA = 0.55, spot size \sim 1.8 μ m at fundamental wavelength). The generated SH signal was then back collected by the same lens, separated using a dichroic mirror, and filtered by a 405 nm bandpass filter before entering a spectrometer (PI Acton 2500i with a liquid nitrogen cooled charge coupled device – CCD camera). The signal value of the spectrometer was calibrated using an attenuated (by neutral density filters) SH signal separately generated from a BBO crystal with known power measured by a power meter (Newport 1830-C). In order to assist the alignment and ensure that the signal was collected from a WS₂ monolayer island, an imaging system was co-set up so that a removable mirror could direct the image signal towards an imaging CCD camera. In addition, in order to calculate the susceptibility, the laser pulse width needs to be known *in situ*, i.e. directly on the sample at the focal point of the objective lens. Therefore, we performed a collinear frequency resolved optical gating (cFROG) measurement⁴² by using the same WS₂ sample to determine the pulse width (106 fs, chirped). Although there exists dispersion in the $\chi^{(2)}$ of WS₂ (c.f. fig. 5), with our laser's relatively narrow bandwidth of about 18 nm, this was determined not to be an issue and was confirmed by the agreement of the retrieved spectrum with the measured laser spectrum. WS₂ monolayer may also enable the characterization of complex pulses with broad bandwidth if its susceptibility is pre-calibrated. To measure the polarization dependence, the fundamental beam was first prepared in a circular polarization state using a quarter-wave plate. A broadband polarizer was inserted between the objective lens and the dichroic mirror to serve as both the polarizer for projecting the input fundamental beam into a linear polarization state and the analyzer for the generated SHG signal. The polarizer was mounted on a computer-controlled rotational stage to continuously rotate its polarization axis.

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Author contributions

C.J., D.M. and N.M. performed SHG characterization and analysis. A.L.E. and N.P.L. synthesized samples. Y.W. performed DFT calculation. Z.L., M.T. and V.C. supervised the project.

Additional information

Competing financial interests: The authors declare no competing financial interests.

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